

Probing van der Waals interactions at two-dimensional heterointerfaces

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Two-dimensional (2D) heterostructures assembled via van der Waals (vdW) interactions have sparked immense interest in fields from physics^{1,2} to electronics^{3,4}. Understanding the vdW interaction at these heterointerfaces is critical for the sophisticated construction and manipulation of these 2D heterostructures. However, previous experimental research has mainly focused on the interlayer interactions in homogeneous graphite crystals^{5,6} and the interactions between graphene and substrates⁷. Theoretically, although a variety of vdW methods have been incorporated in density functional theory to probe the interactions of homogeneous vdW crystals, the reliability of these vdW methods in 2D heterostructures remains to be verified. Here, we show, by contact-splitting transfer of graphite from hexagonal boron nitride (BN) to molybdenum disulfide (MoS₂), that graphite experiences a stronger vdW interaction with MoS₂ than with boron nitride. Quantitative measurements using a graphite-wrapped atomic force microscope tip show that the critical adhesion pressures between BN and graphite and MoS₂ and graphite are respectively 0.953 and 1.028 times that between graphite and graphite. The results are consistent with the prediction based on Lifshitz theory, implying an important role of material dielectric function in the vdW interactions at heterointerfaces. These findings offer us more freedom in the construction of 2D heterostructures, and a technique to disassemble 2D heterostructures is demonstrated.

Van der Waals interactions in 2D heterostructures were investigated experimentally using two different strategies, quantitative measurements of the critical adhesion force at the nanoscale using an atomic force microscope (AFM) with a graphite-wrapped tip and qualitative comparison through contact-splitting tests at the microscale. Graphite, hexagonal BN and MoS₂ are chosen as three typical 2D materials with very different electrical properties to probe the vdW interactions at heterointerfaces. For conciseness, we mainly focus on the graphite–BN and graphite–MoS₂ interfaces in this work. Although the monolayers of these vdW crystals are all in the form of a hexagonal lattice (Fig. 1a), MoS₂ consists of two surface sulfur layers and one interior molybdenum layer, unlike the single-atomic thin graphene and BN. The surface density of the top sulfur atoms of the MoS₂ in direct contact with neighbouring material is ~ 10 atoms nm⁻², which is ~ 3.2 times sparser than that of BN and graphite. Simply assuming the validity of the proportional relationship between the vdW interaction and surface atom density and ignoring the element difference will lead to an intuitive judgement that the critical adhesion force between MoS₂ and graphite should be significantly lower than that of BN and graphite, but this is not the case, as described in the following.

AFM has shown its versatility in probing the mechanical properties of systems from nanomaterials to biological samples. To elucidate the vdW interactions between different 2D materials, a silicon AFM tip was wrapped with a thin graphite flake of thickness ~ 10 nm, as schematically illustrated in Fig. 1b. The wrapping process was carefully designed and conducted to prevent possible contamination on top of the graphite surface (see Supplementary Information for details and Supplementary Fig. 1a). Force–distance curves were measured in high vacuum (1×10^{-7} torr) at room temperature ($\sim 25^\circ\text{C}$) to eliminate contributions from water capillary action between the tip and flake. The BN and MoS₂ flake were aligned on top of the graphite flake (Supplementary Fig. 2c), enabling the characterization of all three materials on the same sample. Before measuring the force–distance curves, the AFM tip was brought into contact with the substrate, which was then annealed in situ at 200°C to remove the airborne hydrocarbon adsorbed on both substrates and graphite tip⁸.

Typical force–distance curves for the three substrates are shown in Fig. 1c. In the approach stage (wine-coloured arrow), the tip first jumped to contact the substrate once the gradient of the attractive force exceeded the probe cantilever stiffness, and then was further pushed towards the substrate with a linear increase in the applied force. During retraction (red arrow), the applied force was released linearly and became negative until the elastic force of the cantilever exceeded the critical adhesion force, where the tip jumped from contact. The discrepancy in the slopes of the approach and retraction lines is attributed to the hysteresis effect of the piezoelectric scanning stage. Once the contact area between the tip and substrate is known, the critical adhesion force between the graphite and BN or MoS₂ could be directly deduced.

Unfortunately, it is always challenging to precisely determine the contact area between a AFM tip and a substrate, especially with the graphite-wrapped AFM tip, where the graphite flake has to crumple to conform to the tip shape (Supplementary Fig. 2b). We therefore measured the critical adhesion forces between different pairs of materials, that is, graphite–graphite ($P_{G/G}$), graphite–BN ($P_{BN/G}$) and graphite–MoS₂ ($P_{MoS_2/G}$), using the same tip. The critical adhesion pressures between graphite–BN and graphite–MoS₂ were then deduced from their ratios to the pressure between incommensurate graphite–graphite, which has been determined to be 1.1 ± 0.15 GPa (refs. ^{9–11}). The stability of the measured adhesion force during 100 measurements (Supplementary Figs. 3 and 4) indicates that there is no systemic change of the contact area during the measurements, and the statistical results for $P_{G/G}$ are shown in Fig. 1d. Histograms $P_{BN/G}/P_{G/G}$ and $P_{MoS_2/G}/P_{G/G}$ are presented in Fig. 1e, and it is clear that $P_{BN/G}$ is lower than $P_{MoS_2/G}$. Based on the determined ratios, the critical adhesion pressures for graphite–BN and graphite–MoS₂ are deduced to be 1.049 ± 0.013 GPa and 1.131 ± 0.014 GPa, respectively.

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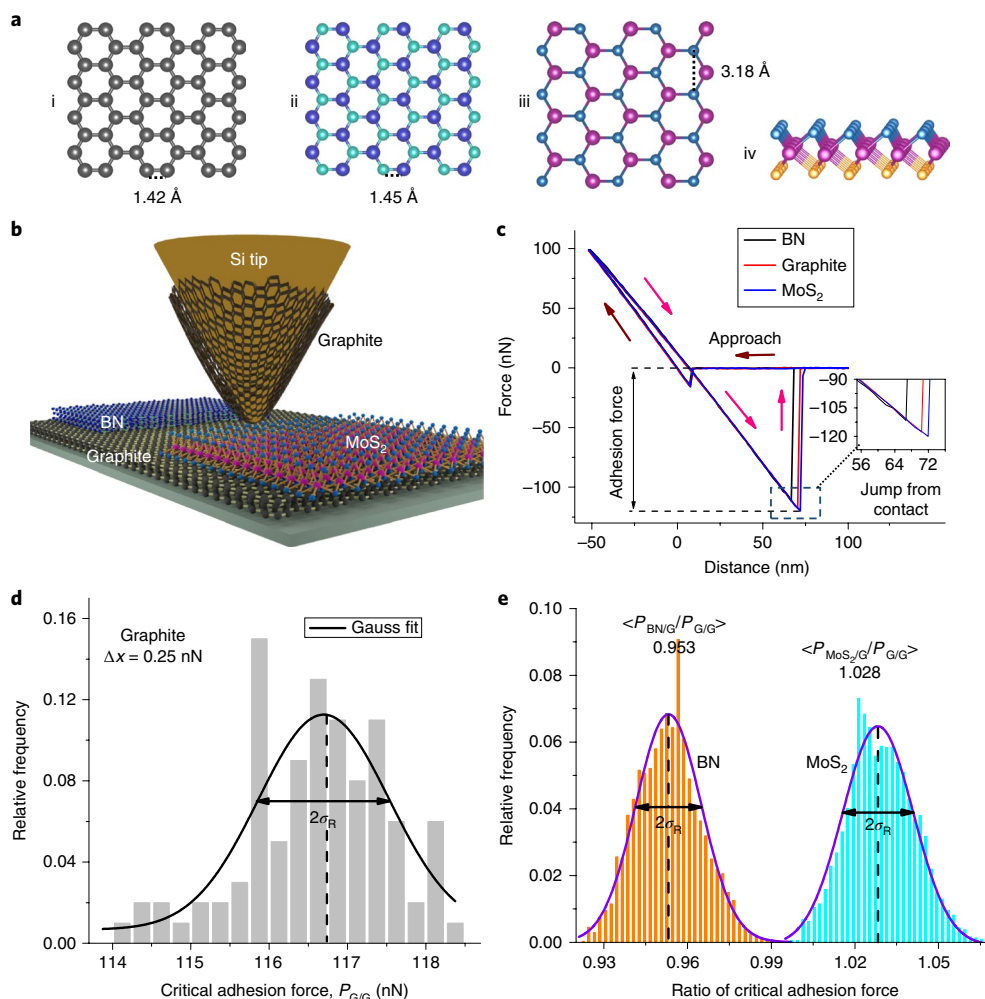


Fig. 1 | Critical adhesion force between 2D materials measured by an atomic force microscope. **a**, Lattice constant and surface atoms of graphite (i), BN (ii) and MoS₂ (iii, iv), where the top- and bottom-layer sulfur atoms in MoS₂ are shown in blue and yellow, respectively. **b**, Schematic illustration of an AFM tip wrapped with a thin graphite layer in contact with BN–MoS₂/graphite. **c**, Typical force–distance curves measured on BN, MoS₂ and graphite, respectively. Inset, Enlarged view of the critical adhesion force. **d**, Histogram distribution of graphite–graphite critical adhesion force $P_{G/G}$ determined in 100 measurements. The black line is a Gaussian fit with a sampling interval of $\Delta x = 0.25$ nN. **e**, Histogram distribution of the ratio of measured critical adhesion forces in graphite–BN ($P_{BN/G}/P_{G/G}$) and graphite–MoS₂ ($P_{MoS_2/G}/P_{G/G}$) to that in graphite–graphite ($P_{G/G}$), respectively. A total of 100 measurements were performed on each pair. Instead of obtaining the $P_{BN/G}/P_{G/G}$ ratio by dividing the $P_{BN/G}$ by the mean of $P_{G/G}$, 10,000 values of the $P_{BN/G}/P_{G/G}$ ratio were calculated by dividing every measured $P_{BN/G}$ value by every measured $P_{G/G}$ and using this for the fitting. In this way, the deviation in the $P_{G/G}$ data fitting is preserved. The same method was applied to obtain the $P_{MoS_2/G}/P_{G/G}$ ratio. The data were recorded at a sampling interval of $\Delta x = 0.002$, and Gaussian fits (violet line) provide $P_{MoS_2/G}/P_{G/G} = 1.028 \pm 0.013$ and $P_{BN/G}/P_{G/G} = 0.953 \pm 0.012$. σ_R in **d** and **e** means the standard deviation in the Gaussian fits.

In the AFM measurements, the relative crystalline orientations between the graphite tip and substrates are random. To investigate if the results are dependent on stacking orientations, we developed a microscale contact-splitting competition strategy to compare their interlayer interaction qualitatively. As illustrated in Fig. 2a, the contact-splitting test consists of three steps. First, two flexible polymer substrates were used to separately pick up large BN and MoS₂ flakes (thickness ~50–70 nm). One of the flake/polymer substrates was then used to pick up a small graphite flake of thickness ~5–15 nm (left panel of Fig. 2a). The 50–70 nm thickness of the BN and MoS₂ flakes ensures that the vdW contribution from the polymers can be ignored. During the pick-up process, the relative angle between the straight edges of two flakes was adjusted to the desired values within an error of 2°. Because the edges of all three materials prefer to be along the zigzag/armchair orientations, the stacking orientations between them can be feasibly controlled in this way¹².

The pick-up process was conducted at around 90 °C to prevent the accumulation of trapped contamination between two flakes, as evidenced by the absence of trapped bubbles between the stacked flakes (Supplementary Fig. 5). The self-cleansing process spontaneously taking place at their interfaces guarantees the atomically clean interface¹³ required for investigation of the vdW interaction. The two polymer substrates were then pushed towards each other until the graphite flake was totally encapsulated by BN and MoS₂, but with the BN and MoS₂ still partially separated (middle panel of Fig. 2a). During this process, the straight edges of the BN and MoS₂ were also aligned parallel to ensure that they had the same stacking orientation to the graphite. Finally, the BN–graphite–MoS₂ stack was split along the BN–MoS₂ interface, and optical images were taken to check to which material the graphite flake was stuck.

As shown in Fig. 2b, all of the graphite flakes were transferred from BN onto MoS₂ flakes after the contact-splitting tests,

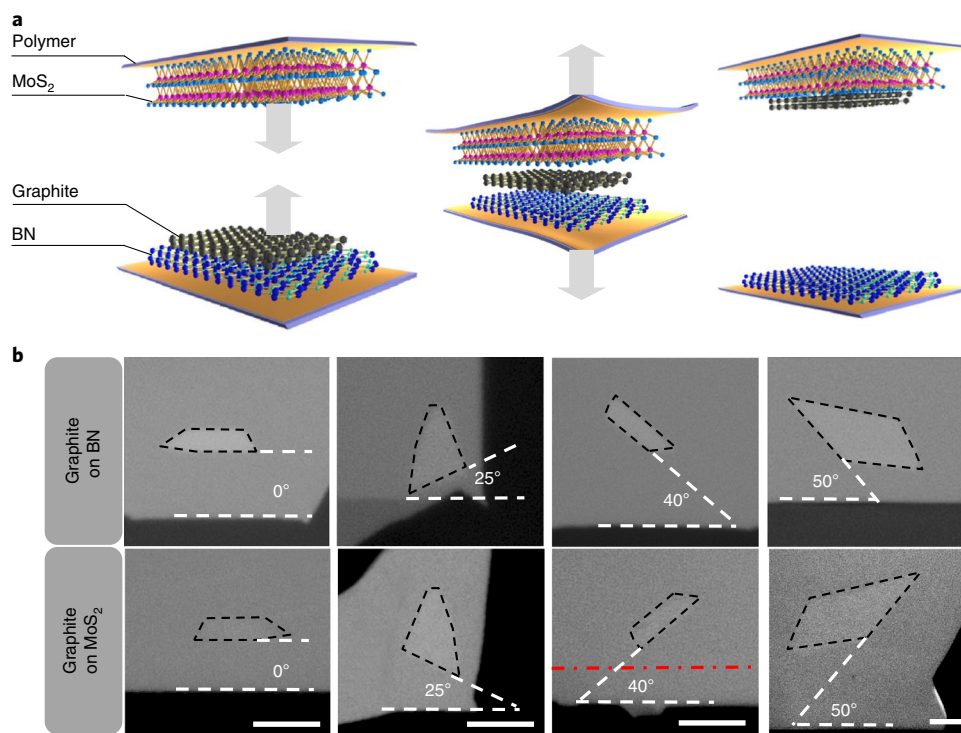


Fig. 2 | Contact-splitting competition test of BN-graphite-MoS₂. **a**, Schematic illustration of the contact-splitting competition test. A graphite-BN stack and MoS₂ flake (or graphite-MoS₂ and BN) were first prepared on flexible polymer substrates (left) and then put into contact with each other until the graphite was fully encapsulated (middle). Finally, the BN-graphite-MoS₂ stack was split along the MoS₂-BN interface to see to which material the graphite flake preferred to stick (right). **b**, Optical images of the results for BN-graphite-MoS₂ stacks of different stacking orientations. Scale bars, 5 μm. The red dashed-dotted line in the bottom panel marks the position where the top and bottom sections of the original micrograph are stitched together while a middle section is removed, and the edges of graphite and MoS₂ flakes shown in the figure are brought closer without relative rotation.

regardless of the stacking orientation (0°, 25°, 40° or 50°). When we performed inverse contact-splitting process by first picking up graphite using MoS₂, the graphite flake never transferred from MoS₂ to BN. During the contact-splitting test, all the other factors remain the same except for MoS₂ and BN flake which are in direct contact with graphite; thus it is reasonable to infer that it is the vdW interaction at the graphite-BN and graphite-MoS₂ interfaces that determines to which materials graphite prefers to adhere. The results of contact-splitting tests also indicate a stronger vdW interaction at the graphite-MoS₂ interface compared with graphite-BN interface regardless of the relative crystalline orientations, which is consistent with the AFM measurements. The orientation independence is further confirmed by the contact-splitting test with random flake orientations (Supplementary Fig. 6).

To understand the experimental results, we performed density functional theory (DFT) calculations using the Perdew-Burke-Ernzerhof (PBE) exchange-correlation functional¹⁴. Because the PBE functional lacks the long-range vdW interactions, five DFT-based vdW methods were applied: (1) many-body-dispersion methods¹⁵, (2) Grimme's DFT+D2¹⁶, (3) vdW-DF¹⁷, (4) the non-local vdW functionals OPT88¹⁸ and (5) Tkatchenko and Scheffler's (TS) vdW method¹⁹. These methods have been widely applied in molecular crystals²⁰, solid materials²¹, metal-organic frameworks^{22,23} and biomolecules²⁴, and have been benchmarked in homogeneous vdW crystals with experimental results or random phase approximation calculations²⁵. In the calculations, we simulated the heterostructures using stacked monolayer crystals instead of flakes of experimental thickness due to limitations in computational resources. Although the thicknesses of the flakes do affect the calculated vdW energy, the qualitative conclusion does not depend on it, as discussed in the Methods.

Figure 3a show the interlayer binding energy as a function of displacement away from the corresponding equilibrium positions for the graphene-BN and graphene-MoS₂ heterostructures, respectively. It can be seen that, once the long-range dispersion interactions are included, the binding energies become negative at the equilibrium positions and converge to zero at infinitely large displacement. The equilibrium distance d_0 , binding energy E_b and critical adhesion force P_c calculated by the five vdW methods are listed in Supplementary Table 1. In general, all the vdW models predict a stronger binding energy in the graphene-BN interface, except for the vdW-DF method, which leads to quite close binding energies. With respect to the critical adhesion force that dominates the splitting process, all the methods predict a higher P_c in graphene-BN (Fig. 3b), which is in conflict with the experimental results. According to test simulations, this inconsistency cannot be attributed to the presence of the sulfur vacancies usually observed in MoS₂. The pairwise vdW methods using vdW coefficients and atomic polarizabilities derived from free atoms ignore the effect of covalent bonding and dipole-dipole screening on material dielectric functions, which might be the reasons for the inconsistencies with experiment.

To find a theoretical vision that can distinguish the difference in the vdW interactions at the 2D heterointerfaces, we calculated the interlayer vdW energies from the dielectric functions of the vdW crystals. According to Lifshitz theory (LZ)^{26,27}, the vdW energy was calculated as the difference between the free energy of electromagnetic modes propagating between two dielectric slabs (as illustrated in Fig. 4a) and the free energy in two isolated slabs. The frequency-dependent dielectric functions obtained from random phase approximation²⁸ (Fig. 4b) were used to calculate the allowed electromagnetic modes, thus taking into account the effect of

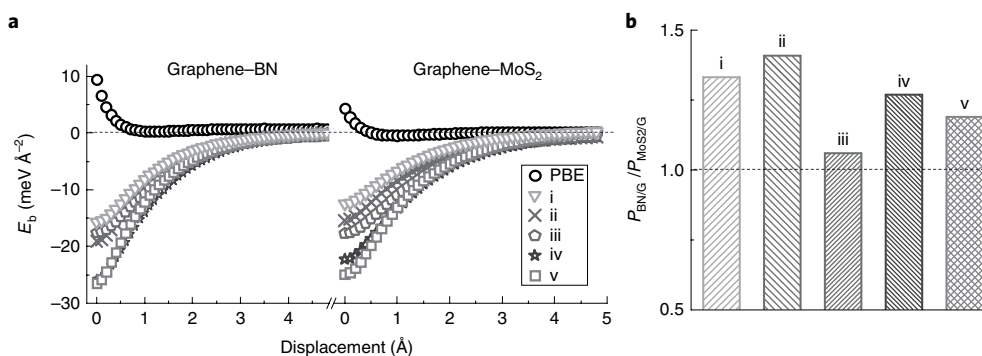


Fig. 3 | Interlayer interactions calculated by DFT-based vdW methods. **a**, Binding energies as a function of interlayer displacement from corresponding equilibrium positions in graphene-BN and graphene-MoS₂ heterostructures. The zero displacement in PBE is set to that in PBE+D2. **b**, Critical force ratio of graphene-BN to graphene-MoS₂ deduced from DFT calculations: (i) many-body dispersion methods; (ii) Grimme's DFT+D2, (iii) vdW-DF, (iv) the non-local vdW functionals OPT88 and (v) Tkatchenko and Scheffler's vdW method.

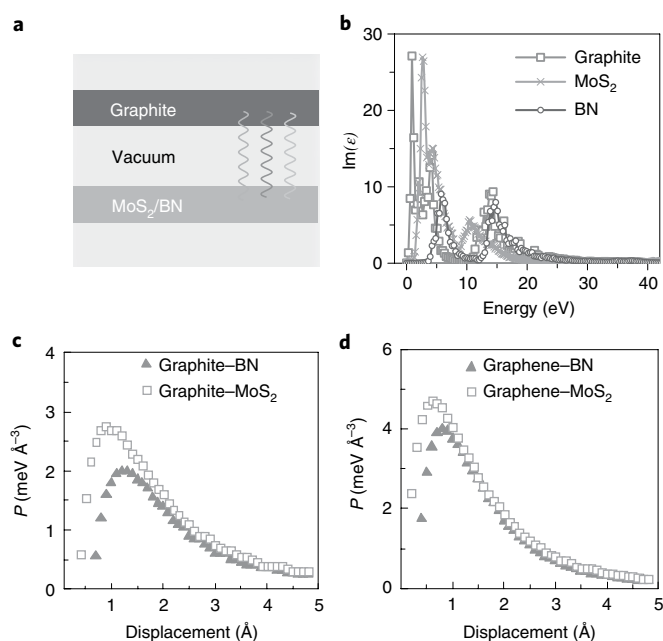


Fig. 4 | Interlayer force derived from Lifshitz theory. **a**, Illustration of the model used in Lifshitz theory. **b**, Imaginary dielectric function of the bulk vdW crystals calculated using the random phase approximation. The real part of the dielectric function was derived from the imaginary part according to the Kramers-Kronig relation. **c**, Force as a function of inter-slab displacement for 5 nm graphite-5 nm BN and for 5 nm graphite-5 nm MoS₂. The equilibrium positions of PBE+D2 are taken as the zero displacement. The surface thicknesses of the electron clouds of the bulk slabs are set at 0.5 Å. The total energy includes both the PBE electrostatic energy and the LZ vdW energies. **d**, Force per unit area as a function of interlayer displacement for graphene-BN and graphene-MoS₂ heterogeneous bilayers. The surface thicknesses of monolayer graphene, BN and MoS₂ are set as 0.77, 0.82 and 0.68 Å, respectively.

covalent bonding and dipole-dipole screening on vdW energy. Figure 4c shows the PBE+LZ interfacial forces as a function of vertical displacement for 5 nm slabs of graphite, BN and MoS₂. Consistent with our experiments, the PBE+LZ critical force in the graphite-MoS₂ heterointerface is higher. This is understandable as MoS₂ having higher imaginary dielectric constants than BN, especially in the low-frequency region. Meanwhile, the weaker PBE elec-

trostatic repulsion in the graphite-MoS₂ heterointerface (Fig. 3a) also contributes to its stronger binding. Figure 4d shows the PBE+LZ interfacial forces in the heterogeneous bilayers, showing the same relative strength of the vdW interaction. It is worth noting that the critical adhesion forces for the monolayers are higher than those of thicker slabs, which should be common for all vdW crystals, because the vdW energy as a function of distance for the monolayers complies with a power law relation different from that for the bulk²⁹. The agreement between the LZ model and our experiment implies an important role of material dielectric function in determining the vdW interactions in heterointerfaces. To further verify this implication, contact-splitting tests were conducted for BN-graphite-MoS₂ (Supplementary Fig. 7). As expected, graphite prefers to stick to MoSe₂ instead of BN, as the dielectric constant of MoSe₂ is comparable to that of MoS₂(ref. 30) and higher than that of BN.

Our additional experiments show that MoS₂ not only wins the competition with BN to attract graphite, but also exerts a stronger attraction to BN compared with graphite (Supplementary Fig. 8). Based on these results, we demonstrated that a graphite-BN-graphite heterostructure can be disassembled flake by flake using MoS₂ as a manipulator, as shown in Fig. 5. The most important thing here is that, after these manipulations, the surfaces of these 2D materials are still atomic clean without introduced defects and contaminations. The technique demonstrated here offers us broader space to manipulate the 2D heterostructures and probe their extraordinary properties.

Conclusion

The vdW interactions at graphite-graphite, graphite-MoS₂ and graphite-BN interfaces are systematically investigated through AFM measurements using a graphite-wrapped AFM tip and a contact-splitting competition experiment. It is revealed that MoS₂ always experiences a stronger attraction to graphite compared with BN regardless of their relative stacking orientations. Quantitative measurements show that $P_{\text{BN/G}}$ and $P_{\text{MoS}_2/\text{G}}$ are 0.953 and 1.028 times $P_{\text{G/G}}$, respectively. Lifshitz theory, which takes the material dielectric function into account, can rationalize the interactive forces at the heterointerfaces, but five commonly used DFT-based vdW models, which are mainly benchmarked for homogeneous interfaces, cannot describe the experimental results. These results imply that the material dielectric function plays an important role in determining the vdW interactions at the heterointerfaces, which is further checked by comparing the strength of interaction at the graphite-MoS₂ and graphite-BN heterointerfaces. Based on these results, a technique to disassemble 2D heterostructures has been developed and demonstrated, offering us more freedom in the construction of 2D heterostructures and their applications.

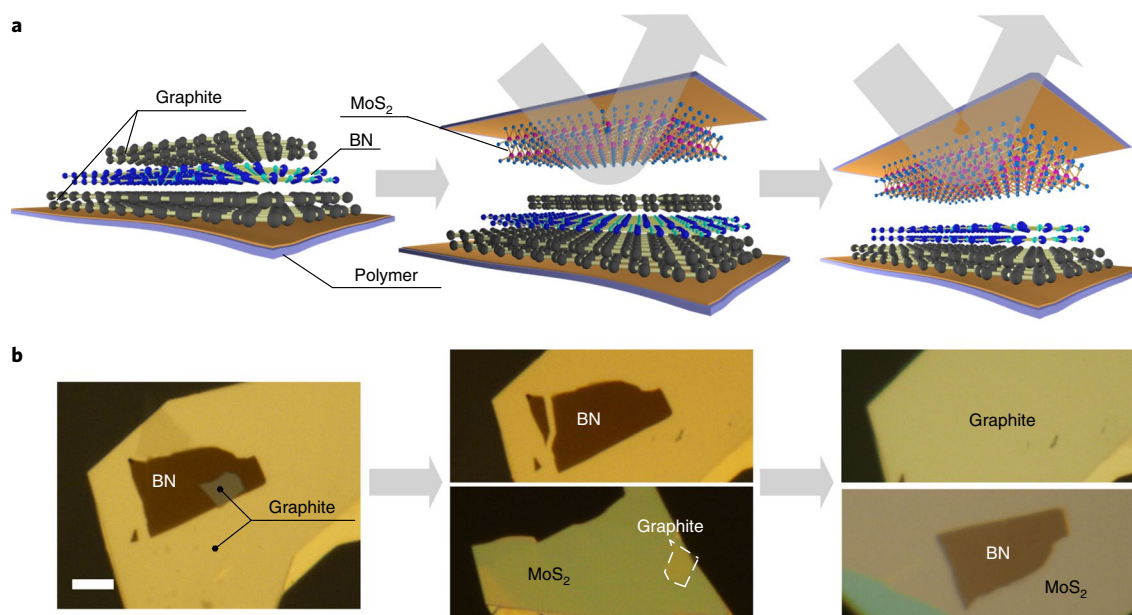


Fig. 5 | Disassembling the graphite-BN-graphite heterostructure, flake by flake, using MoS₂ as a manipulator. a, Schematic illustration of the disassembly process. **b**, Optical images of the original graphite-BN-graphite stack (left), whose top graphite was first removed (middle) followed by removal of the BN flake (right). Scale bar, 5 μm.

Online content

Any methods, additional references, Nature Research reporting summaries, source data, statements of data availability and associated accession codes are available at <https://doi.org/10.1038/s41565-019-0405-2>.

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Author contributions

W.G., J.Y. and B.L. designed the experimental strategy. B.L., J.Y. and H.W. performed the experiments. X. Liu designed and performed the theoretical study. All authors contributed to the analysis and discussion. W.G., B.L., J.Y. and X. Liu wrote the manuscript.

Competing interests

The authors declare no competing interests.

Additional information

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Methods

AFM tip preparation. Graphite flakes were mechanically exfoliated from Kish graphite onto a SiO₂/Si substrate. A graphite flake with thickness of ~10 nm was chosen, then polypropylene carbonate (PPC) film was spin-coated onto the flake at about 2,000 r.p.m. for 60 s and annealed at 100 °C for 5 min. An adhesive tape with a square window was used to lift up the PPC polymer layer with the targeted graphite flake placed at the centre of window. The PPC/graphite film was then reversed and placed on top of an AFM tip with an elastic stiffness of ~2 N m⁻¹ at 60–100 °C. The AFM tip was annealed in vacuum (~1 × 10⁻³ Pa) at ~500 °C to remove the PPC polymer, ensuring that the top surface of the graphite flake, which was never in contact with the PPC polymer and organic solvents, was clean. Details of the fabrication process for the substrate are similar to those for the preparation of the graphite-wrapped AFM tip.

Contact-splitting test. Graphite, BN and MoS₂ flakes were mechanically exfoliated onto SiO₂/Si substrate. A polydimethylsiloxane block was placed on a glass slide and covered by a PPC film, which was then thermally annealed

at ~110 °C for 10 min. The slides were used to pick up the desired flakes and compare the interlayer interactions according to the procedures mentioned in the main text.

DFT simulations. The graphene–BN heterostructure was simulated with a unit cell with a 21 × 21 × 1 k-grid, while the graphene–MoS₂ heterostructure was modelled by a supercell containing 4 × 4 graphene cells and 3 × 3 MoS₂ cells, using a 5 × 5 × 1 k-grid. In the graphene–MoS₂ supercell, the misfit strain in the graphene and MoS₂ was –1.5% and 1%, respectively, which did not influence the qualitative results. For calculations of the interlayer binding energy, both the isolated monolayers and the bilayers were fully relaxed until the force on each atom was less than 0.005 eV Å⁻¹. The energies as a function of interlayer distance were calculated and used to derive the interlayer force.

Data availability

The data that support the plots within this paper and other findings of this study are available from the corresponding author upon reasonable request.